

SHEET 1 OF 1

FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY, DOCKET NO. SITECH.004A	APPLICATION NO. 09/674,725
SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT BY APPLICANT		APPLICANTS Shiho Wang et al.	
(USE SEVERAL SHEETS IF NECESSARY)		FILING DATE October 9, 2001	GROUP 1712

U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)	
Dan	4,775,401	10/04/88	Fleming et al.	65	395		
Dan	5,182,236	01/26/93	Caldwell et al.	501	12		
Dan	5,185,020	02/09/93	Satoh et al.	65	404		
Dan	5,236,483	08/17/93	Miyashita et al.	65	17.2		
Dan	5,314,520	05/24/94	Yagi et al.	264	1, 21		
Dan	5,871,558	02/16/99	Takai et al.	65	17.2		
Dan	6,209,357 B1	04/03/01	Bhandarkar et al.	65	395		
Dan	6,442,977 B1	09/03/02	Bhandarkar et al.	65	395		
Dan	2003/0210881 A1	11/13/03	Mendoza et al.	385	132		
Dan	6,732,549 B1	05/11/04	Lum et al.	65	384		

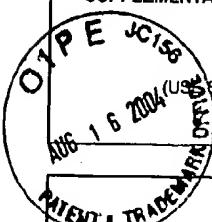
FOREIGN PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
11							
12							
13							
14							
15							
16							

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)
17	
18	
19	
20	
21	

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061104

EXAMINER	<i>Daniel S. McFadden</i>	DATE CONSIDERED	<i>11-24-2004</i>
*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED. INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.			
PAGE 18/20 *RCVD AT 9/20/2004 2:35:56 PM [Eastern Daylight Time] *SVR:USPTO-EFXRF-1/1 *DNIS:8729306 *CSID:9497609502 *DURATION (mm:ss):05:40			

FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE  
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.  
SITECH.004AAPPLICATION NO.  
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BY APPLICANT

(USE SEVERAL SHEETS IF NECESSARY)

APPLICANTS  
Shiho Wang et al.FILING DATE  
October 9, 2001GROUP  
1712

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
DXM	1 4,707,174	11/17/87	Johnson, Jr. et al.	65	395	
DXM	2 4,822,136	04/18/89	Hicks, Jr.	385	142	
DXM	3 4,840,653	06/20/89	Rabinovich	65	395	
DXM	4 5,074,633	12/24/91	Cohen et al.	385	43	
DXM	5 5,123,940	06/23/92	DiGiovanni et al.	501	12	

## FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION		
						YES	NO	
6	JP-141018	08/10/02	Japan (Abstract)	—	—			
DXM	6 JP-59-30730	2-1984	JAPAN (ABSTRACT)	—	—	Abst		
EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)							
DXM	7	Shibata, Shuichi, et al., <i>Fabrication of Fluorine-Doped Silica Glasses by the Sol-Gel Method</i> , <i>Journal of Non-Crystalline Solids</i> , Vol. 100 (1988), pp. 269-273, month unknown						

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081104

EXAMINER	Daniel A. Metzner	DATE CONSIDERED	11 - 26 - 2004
*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.			